

Ref #	Hits	Search Query	DBs	Default Operator	Plurals	Time Stamp
L1	19	(antireflective or antireflection or arl or anti-reflective or anti-reflection) same (sicoh or siohc or sioh or siho or si near2 h near2 o)	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/06/09 08:36
L2	172	(antireflective or antireflection or arl or anti-reflective or anti-reflection or arc or barc) same (resist or photoresist) near3 (poisoning or poisoned or contamination or contaminated)	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/06/09 08:46
L4	135	(sicoh or sioch or sioh or sio:h or si near2 o near2 h or silicon near2 (oxygen or oxide) near2 (hydrogen or hydride or hydrogenated)) same damascene	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/06/09 09:25
L5	186	damascene same (low near k or low near dielectric) same (antireflective or antireflection or anti-reflective or anti-reflection or arl or arc or barc)	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/06/09 10:02
S1	12	"6316167".pn. "6156640".pn. "6147009".pn. "6423630".pn. "20030030057" "20020155386"	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/06/08 17:06
S5	14	(antireflective or antireflection or arl or anti-reflective or anti-reflection) same (sicoh or siohc or sioh or siho or si near2 h near2 o)	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/06/09 08:36
S8	152	(antireflective or antireflection or arl or anti-reflective or anti-reflection or arc or barc) same (resist or photoresist) near3 (poisoning or poisoned or contamination or contaminated)	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/06/09 08:39
S12	113	(sicoh or sioch or sioh or sio:h or si near2 o near2 h or silicon near2 (oxygen or oxide) near2 (hydrogen or hydride or hydrogenated)) same damascene	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/06/09 09:25
S17	168	damascene same (low near k or low near dielectric) same (antireflective or antireflection or anti-reflective or anti-reflection or arl or arc or barc)	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/06/09 09:38
S25	1495	(antireflect\$3 or anti-reflect\$3 or non-reflect\$3 or arl or barc) near20 (oxygen or o! or oxide) near20 (nitrogen or nitride or n!)	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/06/08 17:08
S26	11	(antireflect\$3 or anti-reflect\$3 or non-reflect\$3 or arl or barc) near20 (oxygen or o! or oxide) near20 (nitrogen or nitride or n!) near2 (lack or lacking or little or missing or absent or none or without)	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/06/08 17:20
S27	36	(antireflect\$3 or anti-reflect\$3 or non-reflect\$3 or arl or barc) near15 (sico or sioc or silicon near oxygen near carbide or silicon near carbon near oxide or silicon near carbide near (oxidized or oxygenated or oxide or oxidizing) or si near c near o)	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/06/08 17:13

S28	12	(damascene) and (antireflect\$3 or anti-reflect\$3 or non-reflect\$3 or arl or barc) near10 (nitrogen or nitride or n!) near2 (lack or lacking or little or missing or absent or none or without or free)	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/06/08 17:22
S29	4	"6376392".pn. "20020155386"	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/06/08 17:23